

 **Requisition form for Microwriter at INST**

**(***for Internal Users)*

**Nanoscale Physics and Device Laboratory (NPDL), Institute of Nano Science and Technology,** **Sector-81, SAS Nagar Mohali**

|  |  |
| --- | --- |
| **Name**  |  |
| **Date**  |  |
| **Designation**  |  |
| **E-mail & Mobile no.**  |  |
| **Approx. thickness of sample (including the substrate)\*** |  |
| **Details of photoresist****(Name, Type and Thickness)** |  |
|  **Approx. Dose Required****(mJ/cm2** ) |  |
| **Authorization Data** | **Name of**  | **Signature**  |
| [**Requisitioner**](https://www.google.co.in/url?sa=t&rct=j&q=&esrc=s&source=web&cd=1&cad=rja&uact=8&ved=0CB8QFjAA&url=http%3A%2F%2Fdictionary.reference.com%2Fbrowse%2Frequisitioner&ei=UmSzVLC5Hs6OuAThm4KwCA&usg=AFQjCNHdCMKOmu2g4Dkuk242t5FDBjqb1Q&sig2=Ec2OL0YskH4cw2hI0b-lGg)  |  |  |
| **Supervisor**  |  |  |
|  **Signature of faculty in-charge**  **(Bhanu Prakash, Scientist)**  |
| **Allotted to- Mr. Vibhav / Ms. Renu Rani / Mr. Anirban /** **Mr. Rejaul** |
| **Analysis carried out on:** **Signature (student in-charge)****Difficulty faced, if any:** |

**Note- Not more than one sample per requisition form (one form at a time will be accepted, second requisition only after completion of the previous requisition). Please bring your own photoresist coated sample. You are requested to bring your own design or patterns in CIF file format (Clewin software may be used), please consult with student in-charge for further clarifications.**